

RECEIVED

DEC -4 2002

TECHNOLOGY CENTER 2800

#14C Audt  
J/E M-Baunson  
PATENT APPLICATION 12/6/02  
12/16/02  
1-24-03  
RESPONSE UNDER 37 CFR §1.116  
EXPEDITED PROCEDURE  
TECHNOLOGY CENTER ART UNIT 2874

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Shunji KAMIJIMA et al.

Group Art Unit: 2874

Application No.: 09/581,313

Examiner: J. Kang

Filed: June 12, 2000

Docket No.: 105955

For: MICROMACHINE AND MANUFACTURING METHOD THEREFOR

AMENDMENT AFTER FINAL REJECTION UNDER 37 CFR §1.116

Director of the U.S. Patent and Trademark Office  
Washington, D.C. 20231

Sir:

In reply to the August 20, 2002 Office Action, please amend the above-identified application as follows:

IN THE CLAIMS:

Please replace claims 1 and 11 as follows:

- C1
1. (Thrice Amended) A micromachine comprising:  
a first microstructured portion; and  
a second microstructured portion of a predetermined shape, at least a part of which is formed by mold transfer, the first microstructured portion connected to the second microstructured portion for driving the second microstructured portion to cause substantially all reflected incident light from a light source to travel in a direction almost perpendicular to an area between the first and second microstructured portions.